



2-17-04

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FORM: PTO 1449
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PATENT AND TRADEMARK OFFICEAtty Docket No:
95-0392.02

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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(37CFR 1.98(b))

(use several sheets if necessary)

Applicant:
Sandhu, et al.Filing Date:
November 12, 1999

Group:

U.S. PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Name	Class	Subclass	
pt	AA 5,824,607	10/20/98	Trow et al.	438	732	
	AB 5,817,534	10/06/98	Ye et al.	438	10	
	AC 5,812,403	09/22/98	Fong et al.	364	468.28	
	AD 5,792,272	08/11/98	van Os et al.	118	723 IR	
	AE 5,788,799	08/04/98	Steger et al.	156	345	
	AF 5,788,778	08/04/98	Shang et al.	134	001	
	AG 5,614,055	03/25/97	Fairbairn et al.	156	345	
	AH 5,514,246	05/07/96	Blalock	156	643.1	
	AI 5,409,563	04/25/95	Cathey	156	643	
	AJ 5,393,709	02/28/95	Lur et al.	437	228	
	AK 5,389,496	02/14/95	Calvert et al.	430	315	
	AL 5,389,195	02/14/95	Ouderkirk et al.	156	643	
	AM 5,384,289	01/24/95	Westmoreland	437	245	
	AN 5,368,687	11/29/94	Sandhu et al.	156	664	
	AO 5,252,518	10/12/93	Sandhu et al.	437	200	
	AP 5,240,739	08/31/93	Doan et al.	427	126.1	
	AQ 4,878,994	11/07/89	Jucha et al.	156	643	
	AR 4,820,377	04/11/89	Davis et al.	156	643	
	AS 4,795,880	01/03/89	Hayes et al.	219	121.52	

FOREIGN PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Country	Class	Subclass	Translation Yes No
	AT					<input type="checkbox"/> <input type="checkbox"/>
	AU					<input type="checkbox"/> <input type="checkbox"/>

Initial

OTHER ART (including author, title, date, pertinent pages, etc.)

pt	AV		"Advanced Plasma Sources: What's Working?," <i>Semiconductor International</i> , pp. 56-58, 60, May 1984
	AW		
	AX		

Examiner:

P. Hassan-zadeh

Date Considered:

3-31-04

EXAMINER:

Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication with applicant.